

UNITED STATES PATENT AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER FOR PATENTS P.O. Box 1450 Alexandria, Virginia 22313-1450 www.uspto.gov

DATE MAILED: 03/22/2006

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO
10/724,498	12/01/2003	Donald C. Abbott	28098.1	9998
23494	7590 03/22/2006		EXAMINER	
TEXAS IN	STRUMENTS INCO	NGUYEN, DILINH P		
P O BOX 655474, M/S 3999 DALLAS, TX 75265			ART UNIT	PAPER NUMBER
Diletio, 1	. , , , , , , , , , , , , , , , , , , ,		2814	

Please find below and/or attached an Office communication concerning this application or proceeding.

			E
	Application No.	Applicant(s)	
	10/724,498	ABBOTT ET AL.	
Office Action Summary	Examiner	Art Unit	
	DiLinh Nguyen	2814	
The MAILING DATE of this communication app Period for Reply	ears on the cover sheet	with the correspondence addr	ress
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DOWN - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period vortice to reply within the set or extended period for reply will, by statute Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNI 36(a). In no event, however, may will apply and will expire SIX (6) M , cause the application to become	NICATION. a reply be timely filed ONTHS from the mailing date of this com ABANDONED (35 U.S.C. § 133).	
Status			
Responsive to communication(s) filed on 10 Ja This action is FINAL. 2b) ☐ This Since this application is in condition for alloware closed in accordance with the practice under E	action is non-final. nce except for formal m	· •	merits is
Disposition of Claims			
4) ⊠ Claim(s) <u>17-22</u> is/are pending in the application 4a) Of the above claim(s) is/are withdray 5) □ Claim(s) is/are allowed. 6) ⊠ Claim(s) <u>17-22</u> is/are rejected. 7) □ Claim(s) is/are objected to. 8) □ Claim(s) are subject to restriction and/or	wn from consideration.		
Application Papers			
9) The specification is objected to by the Examine 10) The drawing(s) filed on is/are: a) acc Applicant may not request that any objection to the Replacement drawing sheet(s) including the correct 11) The oath or declaration is objected to by the Ex	epted or b) objected to drawing(s) be held in abey ion is required if the drawi	rance. See 37 CFR 1.85(a). ng(s) is objected to. See 37 CFR	
Priority under 35 U.S.C. § 119			
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority document 2. Certified copies of the priority document 3. Copies of the certified copies of the priority application from the International Bureau * See the attached detailed Office action for a list	s have been received. s have been received ir rity documents have be u (PCT Rule 17.2(a)).	Application No en received in this National S	itage
Attachment(s) 1) Notice of References Cited (PTO-892) 2) Notice of Draftsperson's Patent Drawing Review (PTO-948) 3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date	Paper N	w Summary (PTO-413) lo(s)/Mail Date of Informal Patent Application (PTO-	152)

Application/Control Number: 10/724,498 Page 2

Art Unit: 2814

DETAILED ACTION

Claim Rejections - 35 USC § 103

- 1. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 2. Claims 17-21 are rejected under 35 U.S.C. 103(a) as being unpatentable over Akino et al. (J.P. No. 2000-77593) (previously applied) in view of Huang et al. (U.S. Pat. 5994767) (previously applied) and further in view of Grunwald et al. (U.S. Pat. 3819497) (previously applied).
- Regarding claims 17 and 19, Akino et al. discloses a method for fabricating a
 leadframe comprising the steps of:

providing a copper leadframe 1 base made of copper 5;

depositing a first layer of nickel 6 onto the copper;

electroplating a layer comprising an alloy palladium 7;

electro plating a second layer of nickel 9, thereby adapting the lead segments for mechanical bending;

electroplating a layer of palladium 7; and

a layer of gold 8 (figs. 1-3).

Akino et al. fails to explicitly show gold selectively plated on segments of the leadframe intended for solder attachment and cleaning the leadframe in alkaline soak;

Application/Control Number: 10/724,498

Art Unit: 2814

activating the leadframe by immersing the leadframe into an acid solution and immersing the leadframe into an electrolytic nickel plating solution.

However, Huang et al. disclose a method for fabricating a leadframe comprising the steps of: providing a copper leadframe 30 having a mount pad for an integrated circuit chip 40; a molding compound 46 (cover fig., column 7, lines 43-46) and a plurality of lead segments 30 having their first end near the mounting pad and their second end remote from the mount pad; a copper layer 32; a nickel layer 34; a palladium layer 54 and a gold layer on the lead frame (cover fig.), either over the entire leadframe or selectively only over specific portions of the leadframe (column 2, lines 31-34) thereby would create a visual distinction between the gold plated and unplated leadframe areas for the purpose of making solder connections.

Grunwald et al. disclose a method for fabricating a copper sheet comprising the steps of:

providing a sheet made of copper (column 2, lines 65-66);

cleaning the copper sheet in alkaline soak and electro-cleaning solutions (column 3, lines 4-15);

activating the surface of the copper sheet by immersing the copper sheet into an acid solution (column 3, lines 43-45 and 48-50); and

immersing the activated the copper sheet into a chromating solution including chromic acid and an activator (column 3, lines 51-56) to improve the adhesion for the semiconductor package and reduce complexity of implementation (column 2, lines 53-57).

Art Unit: 2814

Therefore, it would have been obvious to one of ordinary skill in the art to modify the process step of Akino et al. by plating gold selectively on segments of the leadframe and activating the surface of the lead frame by immersing the lead frame into an acid solution because as taught by Huang et al. and Grunwald et al., for the purpose of making solder connection and in order to improve the adhesion for the semiconductor package and reduce complexity of implementation.

- Regarding claim 18, it would have been obvious in the art wherein the gold plating of Huang et al. is performed electrolytically or electrolessly.
- Regarding claim 20, Grunwald et al. disclose the process steps are obviously executed in sequency without time delays, yet including intermediate rinsing steps.
- Regarding claim 21, Grunwald et al. disclose the acid solution may be sulfuric acid and hydrochloric acid (column 6, lines 50-55 and column 7, lines 15-17).
- 3. Claim 22 is rejected under 35 U.S.C. 103(a) as being unpatentable over Huang et al. (U.S. Pat. 5994767) (previously applied) in view of Grunwald et al. (U.S. Pat. 3819497) (previously applied).

Huang et al. (cover fig.) disclose a method for fabricating a leadframe comprising the steps of: providing a copper leadframe 30 having a mount pad for an integrated circuit chip 40 and a plurality of lead segments 30 having their first end near the mounting pad and their second end relatively remote from the mount pad; a copper layer 32; a nickel layer 34; a palladium layer 54 and a gold layer on the lead frame,

either over the entire leadframe or selectively only over specific portions of the leadframe (column 2, lines 31-34) for the purpose of making solder connections.

Huang et al. fail to disclose the step of cleaning the leadframe in alkaline soak; activating the leadframe by immersing the leadframe into an acid solution and immersing the leadframe into an electrolytic nickel plating solution.

Grunwald et al. disclose a method for fabricating a copper sheet comprising the steps of:

providing a sheet made of copper (column 2, lines 65-66);

cleaning the copper sheet in alkaline soak and electro-cleaning solutions (column 3, lines 4-15);

activating the surface of the copper sheet by immersing the copper sheet into an acid solution (column 3, lines 43-45 and 48-50); and

immersing the activated the copper sheet into a chromating solution including chromic acid and an activator (column 3, lines 51-56). Therefore, it would have been obvious to one having ordinary skill in the art to modify the process step of Huang et al. by cleaning the lead frame in alkaline soak and electro-cleaning solutions; activating the surface of the lead frame by immersing the lead frame into an acid solution because as taught by Grunwald et al., in order to improve the adhesion for the semiconductor package and reduce complexity of implementation (column 2, lines 53-57).

Response to Arguments

Applicant's arguments filed 1/10/06 have been fully considered but they are not persuasive.

Art Unit: 2814

 Applicant argues that the Akino et al. reference was supplied in the Japanese language only with no translation included. The rejection is improper on its face and the Akino et al. reference is not available on the present record.

The arguments has been fully considered but it is not persuasive because the Akino et al. reference (2000-77593) had been cited and applied in the cases Serial No. 09/525,105 and 09/589,051 (U.S. Pat. 6376901).

 Applicant argues that Grunwald et al. has nothing whatsoever to do with leadframes.

The argument has been fully consideration but it is not persuasive because Examiner relies on the combined teachings at Huang et al. and Grunwald et al. Huang et al. relied on for showing a lead frame made of copper. Grunwald et al. is relied on for showing a method for fabricating a copper sheet comprising the steps of: activating the surface of the copper sheet by immersing the copper sheet into an acid solution (column 3, lines 43-45 and 48-50); plating a surface layer of copper onto the copper sheet, whereby the layer is inherently deposited in controlled uniformity and consistency (column 4, lines 30-33 and 40-44); and immersing the activated copper sheet into a chromating solution including chromic acid and an activator (column 3, lines 51-56) would converting copper surface atoms into chromate complexes and creating a surface layer comprising chromic and copper reaction products. The Examiner thus regards the Applicant's assertions as constituting evidence that the Applicant has failed to consider as a whole the prior art teachings disclosed by the combining of the references.

Art Unit: 2814

Therefore, it would have been obvious to one having ordinary skill in the art at the time the invention was made to provide a method for fabricating a semiconductor device comprising the steps as set forth above of the copper sheet because as taught by Grunwald et al., into the copper lead frame of Huang et al., in order to improve the adhesion for the semiconductor package and reduce complexity of implementation.

It should be noted that the rejection of claim 22 is not based on anticipation, but rather, are based on obviousness.

• In response to applicant's argument that there is no teaching or suggestion to combine the references, the test for obviousness is not whether the features of a secondary reference may be bodily incorporated into the structure of the primary reference; nor is it that the claimed invention must be expressly suggested in any one or all of the references. Rather, the test is what the combined teachings of the references would have suggested to those of ordinary skill in the art. See *In re Keller*, 642 F.2d 413, 208 USPQ 871 (CCPA 1981).

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any

Application/Control Number: 10/724,498 Page 8

Art Unit: 2814

extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to DiLinh Nguyen whose telephone number is (571) 272-1712. The examiner can normally be reached on 8:00AM - 6:00PM (M-F).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Wael Fahmy can be reached on (571) 272-1705. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DLN

HOAI PHAM